Docket No.: 50432-645 **PATENT** 

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of : Customer Number: 20277

Douglas J. BONSER, et al. : Confirmation Number:

Serial No.: : Group Art Unit:

Filed: March 04, 2004 : Examiner: Unknown

For: METHOD OF REDUCING STI DIVOT FORMATION DURING SEMICONDUCTOR

DEVICE FABRICATION

## INFORMATION DISCLOSURE STATEMENT

Mail Stop IDS Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

## Serial No.:

Please charge any shortage in fees due in connection with the filing of this paper, including extension of time fees, to Deposit Account 500417 and please credit any excess fees to such deposit account.

Respectfully submitted,

MCDERMOTT, WILL & EMERY

Registration No. 26,106

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Date: March 4, 2004

INFORMATION DISCLOSURE CITATION IN AN APPLICATION					ATTY. DOCKET NO. 50432-645		SERIAL NO.			
					APPLICANT Douglas J. BONSER, et al.					
(PTO-1449)					FILING DATE March 04, 2004		GROUP			
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